10540056 - GAU: 1795

PTO/SB/08 Equivalent

	Application No.	10/540,056
INFORMATION DISCLOSURE	Filing Date	June 22, 2005
STATEMENT BY APPLICANT	First Named Inventor	Sato et al.
STATEMENT BY AFFEIGANT	Art Unit	1795
(Multiple sheets used when necessary)	Examiner	John S Y Chu
SHEET 1 OF 2	Attorney Docket No.	SHIGA7.021APC

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Examiner Signature /John Chu/ Date Considered 11/24/2008

\*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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SHEET 2 OF 2	Attorney Docket No.	SHIGA7.021APC

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Examiner Signature	/John Chu/	Da	ate Considered	11/24/2008

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